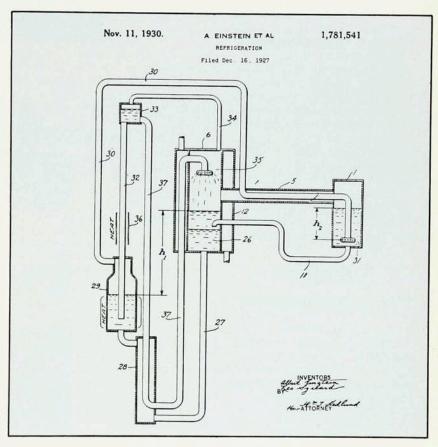
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Einstein as inventor

Georg Alefeld

If I tell people that Einstein invented several important technical devices. usually their reaction is, "Oh yes, he worked at the Swiss patent office in Berne before he made his contributions to theoretical physics." Two things are wrong: First, working at a patent office by no means implies inventive activities and, second, Einstein made his inventions long after he published his important achievements in relativity, thermodynamics and quantum physics. It was nearly a decade after he received the Nobel prize that his inventions were patented. Figure 1 shows his first invention and figure 2 shows a partial list of his patents. The number of papers the 45-50 year-old Einstein published in the patent literature1-19 exceeds by far the number he published in scientific journals. In cooperation with Leo Szilard, his junior by 19 years, the theoretical physicist Einstein had a period of imaginative technical inventions. The patents are more than amusing to read. With the upcoming energy shortage they have received new remarkable relevance, in addition to the fact that some inventions have resulted in hardware that is in widespread use in modern industry.

All Einstein's inventions (except for two) are more or less related to improvements of heat pumps, which in the 1920's were almost exclusively used for refrigeration purposes. Einstein and Szilard started in 1926 with a new concept for the absorption heat pump (figure 1). Although the first absorption heat pump was built as early as 1810 by the Scotsman John Leslie (using water as refrigerant and sulfuric acid as absorbent) the thermodynamic processes involved are still considered complicated today. The work required to lift a certain amount of heat from a lower temperature level to a higher one is not provided as work, as it is for the compressor heat pump, but as heat which has the ability to do work. It can be shown²⁰ that the absorption heat pump consists of two interconnected power cycles; a left-turning (that is, work-consuming) Clausius-Rankine cycle as the real pump and a right-turning (that is, work-producing) two-component Clausius-Rankine sorption cycle as the power



Absorption heat pump without a mechanical pump was first invention of Einstein & Szilard in 1926. Included are generator (29), evaporator (1), condenser & absorber (6).

station. If the pressures and temperatures for the two cycles are suitably chosen, the two cycles can be connected using one common working fluid and eliminating the turbine and the compressor. Four vessels remain: in the work-absorbing cycle the condensor and the evaporator containing the working fluid, and in the work-producing cycle the generator and the absorber containing mixtures of the working and the absorber fluid. The generator and condensor are at high pressure, evaporator and absorber at low pressure. Therefore, a mechanical pump is required to bring the rich solution from the absorber to the generator.

In Einstein's and Szilard's invention (figure 1) this pump is replaced by a third

fluid used as an auxiliary inert gas allowing all parts of the apparatus to be at the same pressure. The fluid is circulated by gravity and a bubble pump in the generator. In contrast to a similar invention by von Platen and Munters that used hydrogen as an inert gas and NH₃/H₂O as working and absorbing fluids, Einstein and Szilard used a condensable gas as pressure equalizing medium. If a refrigerant that does not mix in the liquid state with the pressure equalizing medium is used, this procedure surprisingly eliminates not only the pump and throttle valves but allows the condensor and ab-

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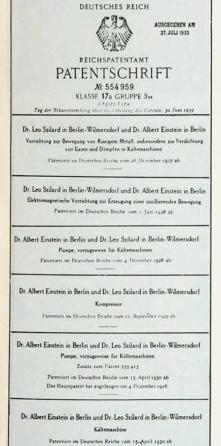
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sorber to be combined into one unit (No. 6 in figure 1). Einstein and Szilard suggested butane or methylbromide as refrigerant, NH₃ as inert gas and water as absorbent for the inert gas (not for the refrigerant!).

Multi-dimensional thinking is needed to follow and analyze the individual thermodynamic steps occurring in the three-component system (for example, the expansion of the refrigerant fluid into NH3 bubbles passing through the evaporator and the compression of the refrigerant fluid by the process of absorption of the NH3 by water). It is not clear to us why the Platen and Munters method was chosen over Einstein's and Szilard's invention as the basis for many million refrigerators. Perhaps the speed of absorption and vaporization in the presence of a third gas was not great enough to make the idea competitive. Further inventions by Einstein and Szilard included other combinations of working fluids and an absorption refrigeration machine in which the liquid is pumped by intermittently increasing the vapor pressure.



Examples of Einstein and Szilard's patents; they obtained a total of 17 patents. Figure 2

Today a new research and development program has been started (at least in Europe) with the aim of using absorption heat pumps for home heating or more generally to "transform" heat between different temperature levels under conservation of entropy. In contrast to electrically driven compressor heat pumps (for which the waste heat created in the work-producing process must be dumped at the power station), the absorber produces the "waste heat" at the temperature level and right at the place at which it can be used for heating. As a result, the efficiency of the absorption heat pump is better than for the electrically driven compressor heat pump. Reliability and low noise also are important requirements for domestic use. Therefore, Einstein's and Szilard's ideas should attract new interest, especially since many more combinations of working fluids are known today. Just recently some of their ideas have been applied on technical scale by the Institut Français du Petrole to upgrade industrial waste heat at a temperature level T_1 to a higher, more useful, temperature level T_2 .

The subsequent patents of Einstein and Szilard deal with improvements of the compressor heat pump. Again the procedure of pumping the fluid-or more precisely, the compression of the gashad attracted the authors attention. Due to their invention of an electromagnetically driven liquid-metal pump it was possible to design hermetically sealed compressor heat pumps without any mechanically moving parts and without the problems of interaction between refrigerants and lubricants. This liquid metal pump, which originally was invented to improve refrigerators, has today become an important technical device with continuously increasing applications, such as a valve, plug or pouring device for liquid metals like aluminum or magnesium alloys or as a pump in sodium-cooled breeder reactors or solar towers.

Einstein and Szilard, in later inventions, concentrated on technical details such as how to keep the metal in the liquid state during periods of interruptions or how to start the pump, and so on. As a by-product Szilard and Einstein invented an electromagnetic motor to produce linear oscillatory motions instead of rotary motions. The principle of this invention, in which springs reverse the motion, looks just tailor-made for application as a generator or motor for the recently developed, and very promising, free-piston Stirling machine in which the cylinders oscillate against gas springs.

There is no doubt that Einstein's and Szilard's contribution in the field of linear electromagnetic devices has stimulated the development of linear motors, which today are the basis for the propulsion of magnetic levitation trains.

For completeness we should mention that Einstein held a patent together with

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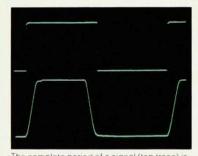
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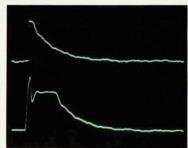
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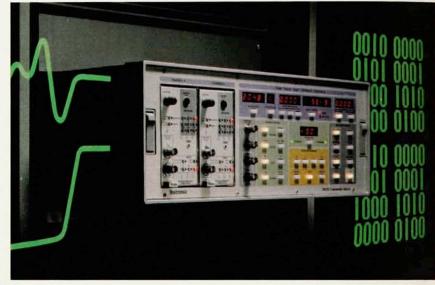
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G. Bucky¹⁸ on a light intensity self-adjusting camera. There is also a patent together with R. Goldschmidt on a hearing aid.19

Einstein is often described as having had a very theoretically oriented mind. In spite of this he was apparently interested and had fun in designing hardware. The sequence of the names on the patents in figure 2 as a function of time indicates how much he identified himself with this work. W. Gerlach²¹ recalled that he once met Einstein in Berlin feeling quite depressed: the patent office had informed him that a refrigerator that he and Szilard had conceived was known and thus could not be patented. What a new experience for a man like Einstein having a "publication" being turned down and declared as previously known. In his own words: "If this would have happened to the theory of Special Relativity . . . '

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